

1050 U.S. PTO

10/079348

02/20/02

^{2c/869}
BEST AVAILABLE COPY

**PATENT NUMBER and
ISSUE DATE**

U.S. UTILITY Patent Application

APPL NUM 10079348	FILING DATE 02/20/2002	CLASS 430	SUBCLASS 18	GAU 1752	EXAMINER ASHTON
**APPLICANTS: Lee Geun; Jung Jae; Shin Ki;					
**CONTINUING DATA V <i>Rev D leave complete ASAP.</i> <i>Mark</i>					
** FOREIGN APPLICATIONS VERIFIED: REPUBLIC OF KOREA 2001-34603 06/19/2001					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no		35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO 30205/38082	
Verified and Acknowledged Examiners's initials					
TITLE : Photoresist monomers, polymers thereof and photoresist compositons containing the same <small>U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)</small>					

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg. Print Fig.
<input type="checkbox"/> TERMINAL DISCLAIMER		Primary Examiner Prepared for Issue Application Examiner	
WARNING: The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368, Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.			

FILED WITH:

☐ DISK (CRF)

☐ CD-ROM

(Attached in pocket on right inside flap)